

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L4	1	(multilayer adj10 resist) and (precise adj5 thickness)	USPAT	2002/07/25 09:59
2	BRS	L7	55	6 and (gold or au)	USPAT	2002/07/25 10:08
3	BRS	L6	656	(removed or removes or removing) adj10 (multilayer or multilayered or organic or molecule or resist) adj10 (residual or residue)	USPAT	2002/07/25 10:33
4	IS&R	L13	9344	(435/6).CCLS.	USPAT	2002/07/25 10:46
5	BRS	L15	448	13 and (multilayered or multilayer or resist or multi-layered)	USPAT	2002/07/25 10:46
6	BRS	L16	298	15 and (residue or residues or residual or residuals)	USPAT	2002/07/25 10:50
7	BRS	L17	1	16 and (adjacent adj lines)	USPAT	2002/07/25 10:54
8	BRS	L19	0	17 and ring	USPAT	2002/07/25 10:54
9	BRS	L18	114	16 and (ring or rings)	USPAT	2002/07/25 10:55

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L2	7441	organic adj molecules	USPAT	2002/07/25 08:40
2	BRS	L3	573	2 and (multilayer or multilayered or (multi adj3 layered) or (multi adj3 layer))	USPAT	2002/07/25 08:41
3	BRS	L4	490	3 and (remove or removed or removing or liftoff or (lift adj3 off))	USPAT	2002/07/25 08:42
4	BRS	L5	358	4 and (residual or residue or remaining)	USPAT	2002/07/25 08:43
5	BRS	L6	366	4 and (residual or residue or remaining or remainder)	USPAT	2002/07/25 08:43
6	BRS	L7	352	6 and (structure or structures)	USPAT	2002/07/25 08:56
7	BRS	L8	19	electronic adj3 beam adj3 lithography	USPAT	2002/07/25 08:59
8	BRS	L9	317	quantum adj dot	USPAT	2002/07/25 09:00